



Skyrmions in SrRuO_3 based heterostructures?

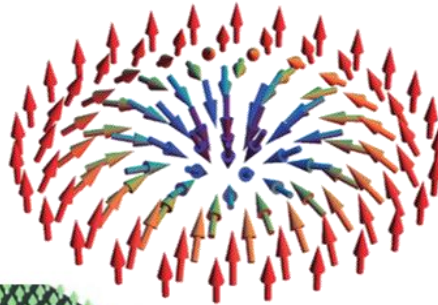
Skyrmionics gets hot

Stefan Krause and Roland Wiesendanger

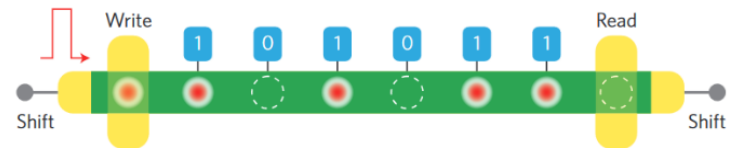
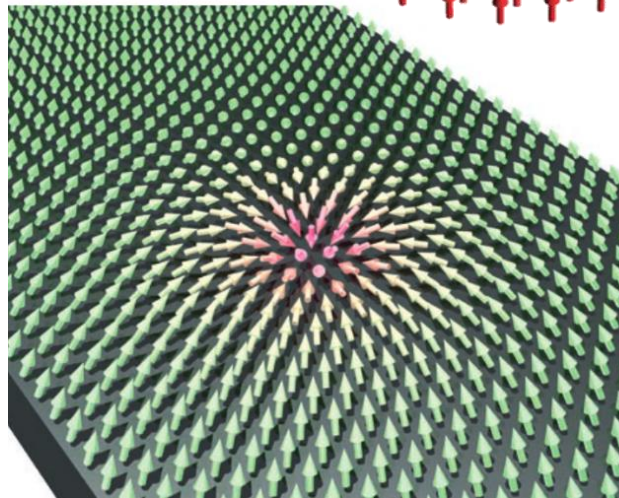
Observed at room temperature
-> ambient conditions

Manipulation by electric currents
-> enables application

Size in the nm range
-> high information
density

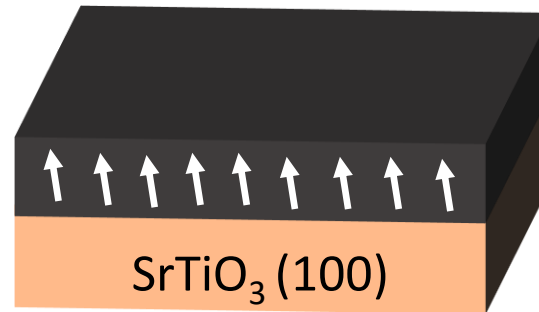
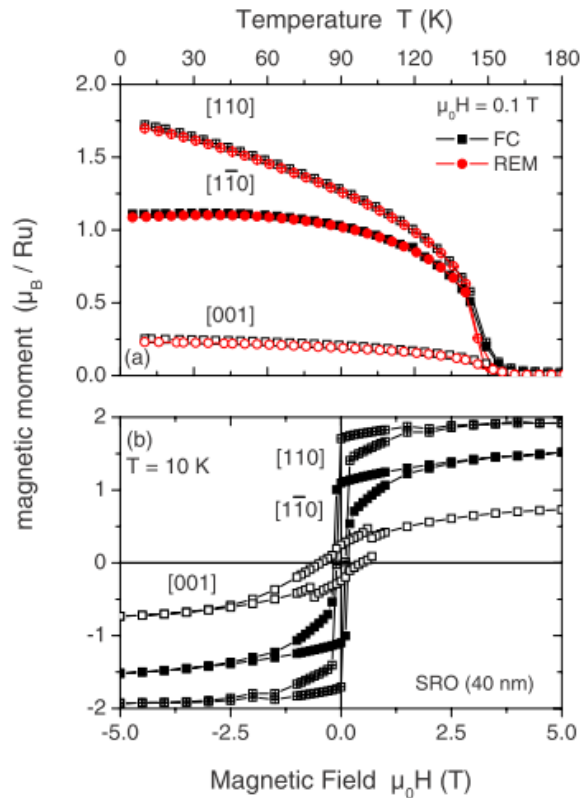


Topological protection
-> stability/reliability

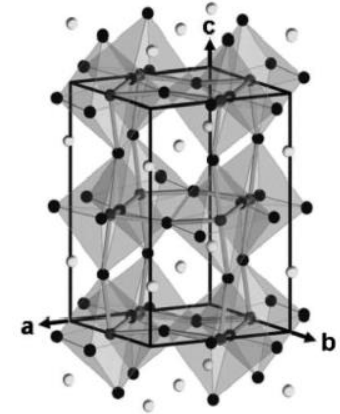


SrRuO₃ based multilayers

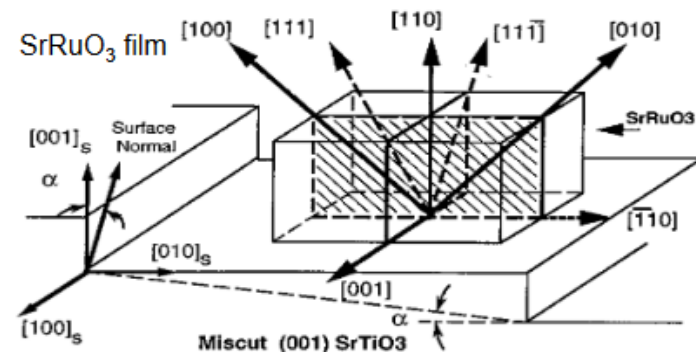
SrRuO₃



Orthorhombic

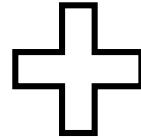


Choi et al., Science 306, 1005 (2004)



Gan et al., APL 85, 5297 (1999)

SrRuO₃ based multilayers

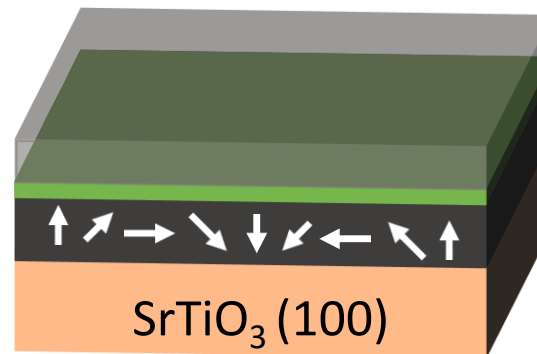
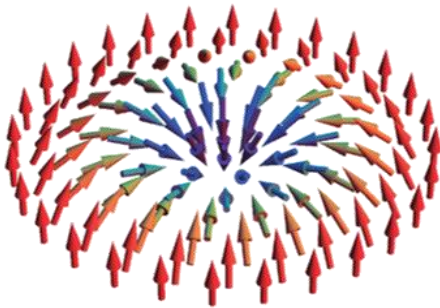


5d *Iridium*

-> strong SOC



skyrmions?

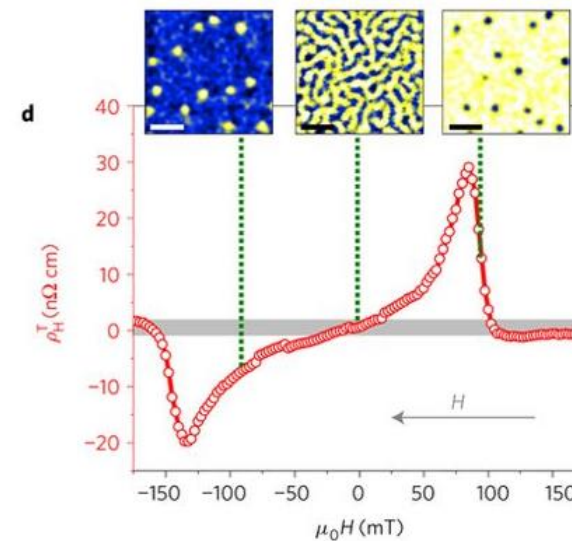
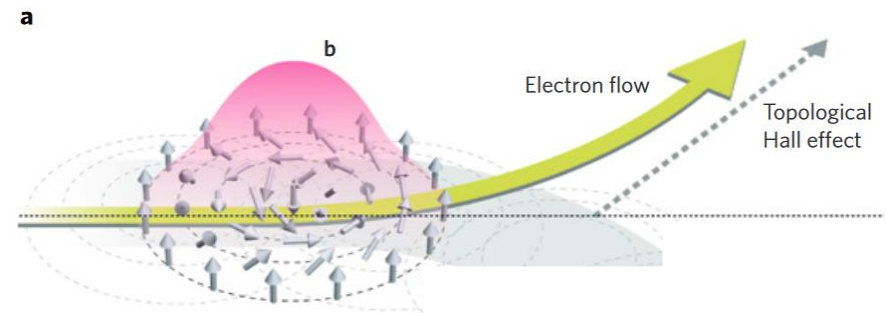
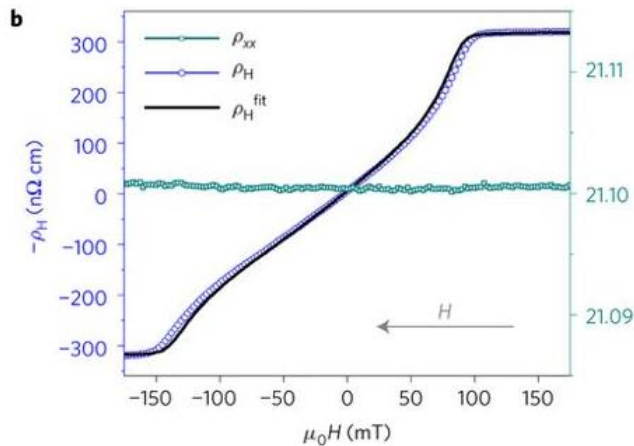
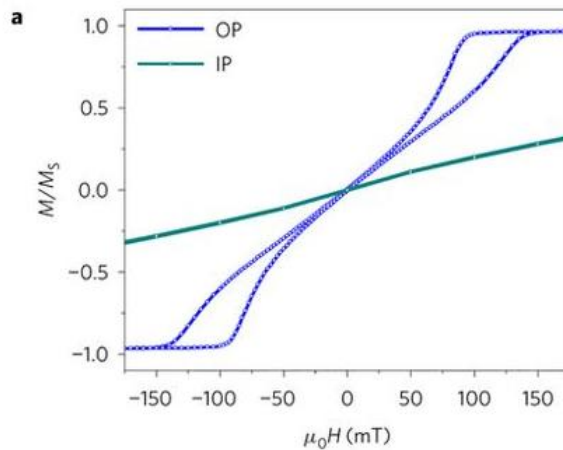


$$\mathbf{H}_{DMI} = -\mathbf{D}_{ij}(\mathbf{S}_i \times \mathbf{S}_j)$$

THE: Fingerprint of skyrmions

Nagaosa, Tokura Nature Nanotechnology, Volume 8 (2013)

$$\rho_{Hall} = R_0 B_z + R A M_z + \rho^{THE}$$

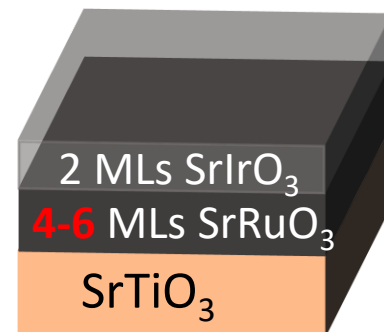


Tunable room-temperature magnetic skyrmions in Ir/Fe/Co/Pt multilayers

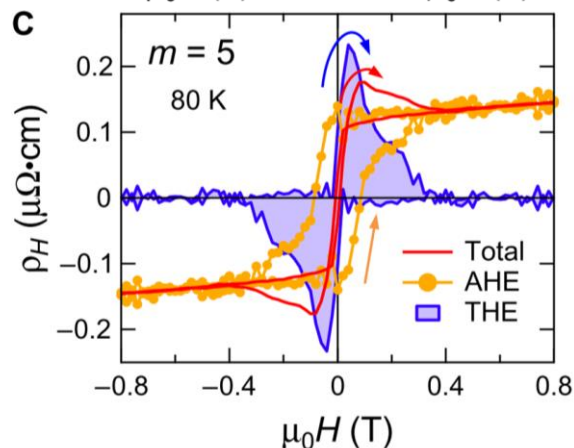
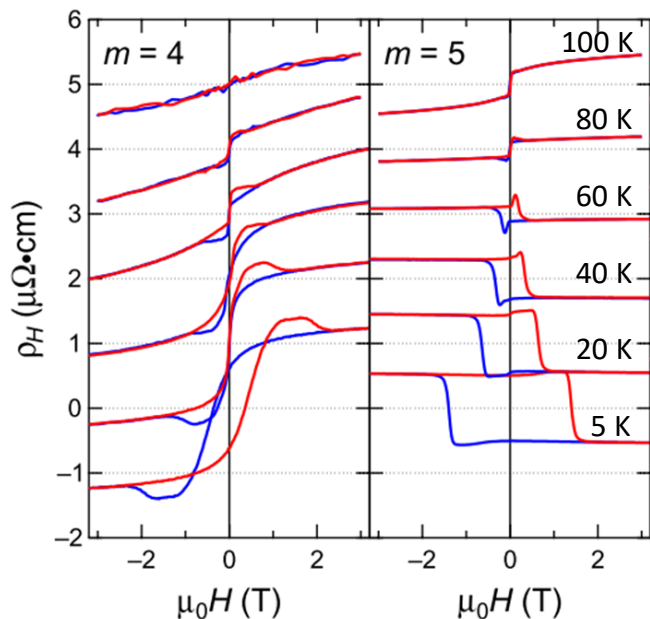
Soumyanarayanan et al., Nature Materials **16**,898-904(2017)

Interface-driven topological Hall effect in SrRuO₃-SrIrO₃ bilayer

Jobu Matsuno,^{1*} Naoki Ogawa,¹ Kenji Yasuda,² Fumitaka Kagawa,¹ Wataru Koshibae,¹ Naoto Nagaosa,^{1,2} Yoshinori Tokura,^{1,2} Masashi Kawasaki^{1,2}



H sweep direction →
←



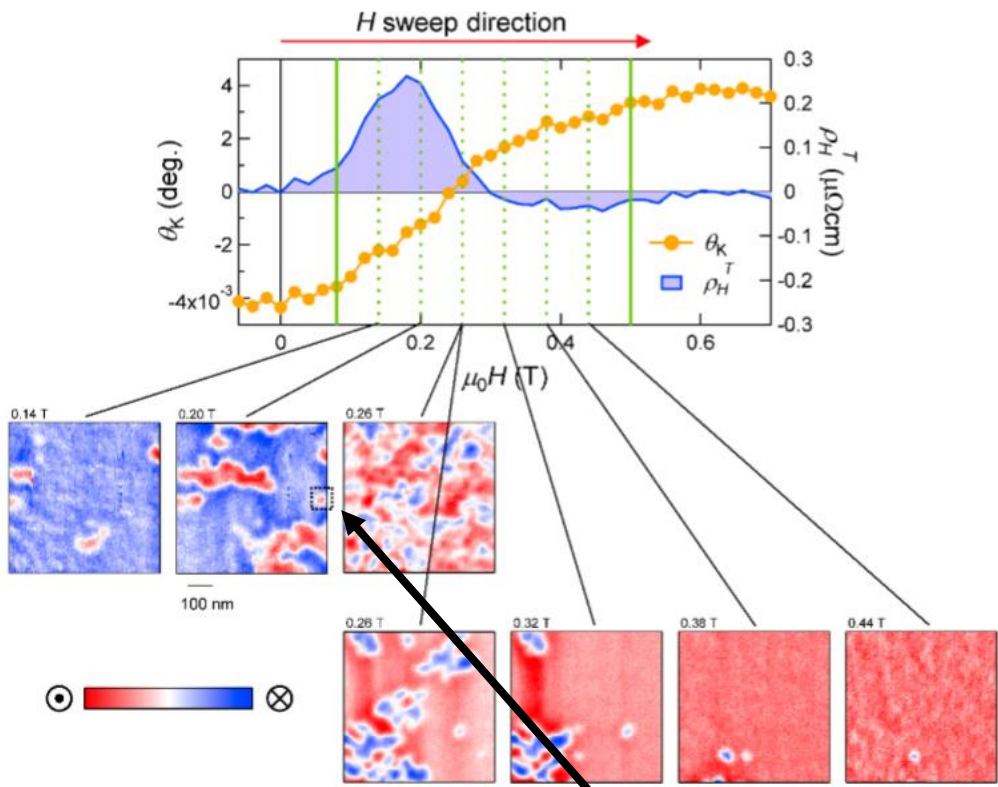
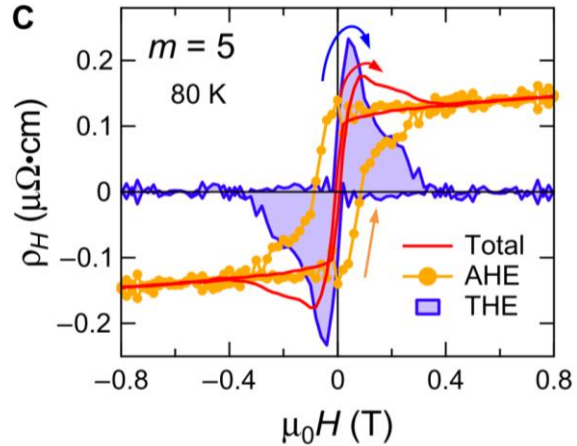
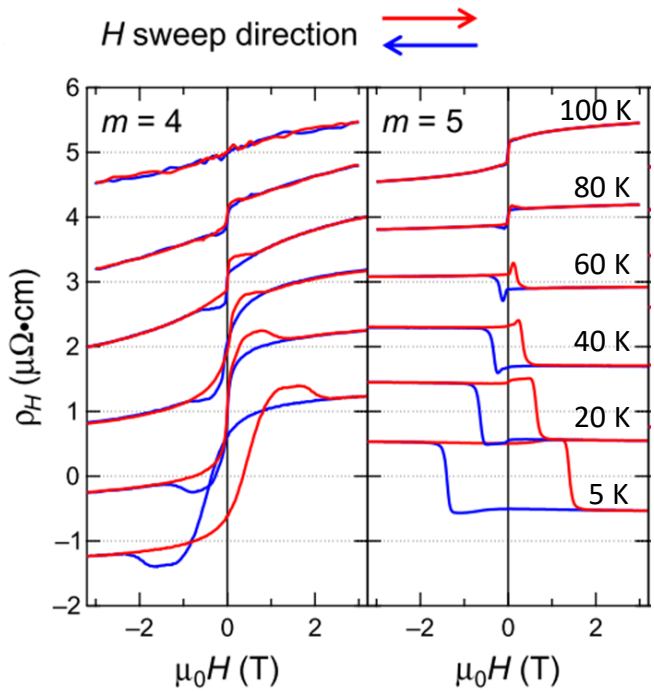
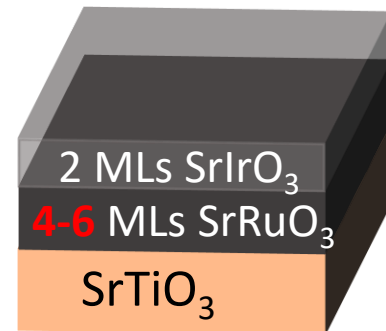
additional contribution to the Hall effect

-> topological Hall effect

-> indication for noncollinear magnetic order

Interface-driven topological Hall effect in SrRuO₃-SrIrO₃ bilayer

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skyrmion!

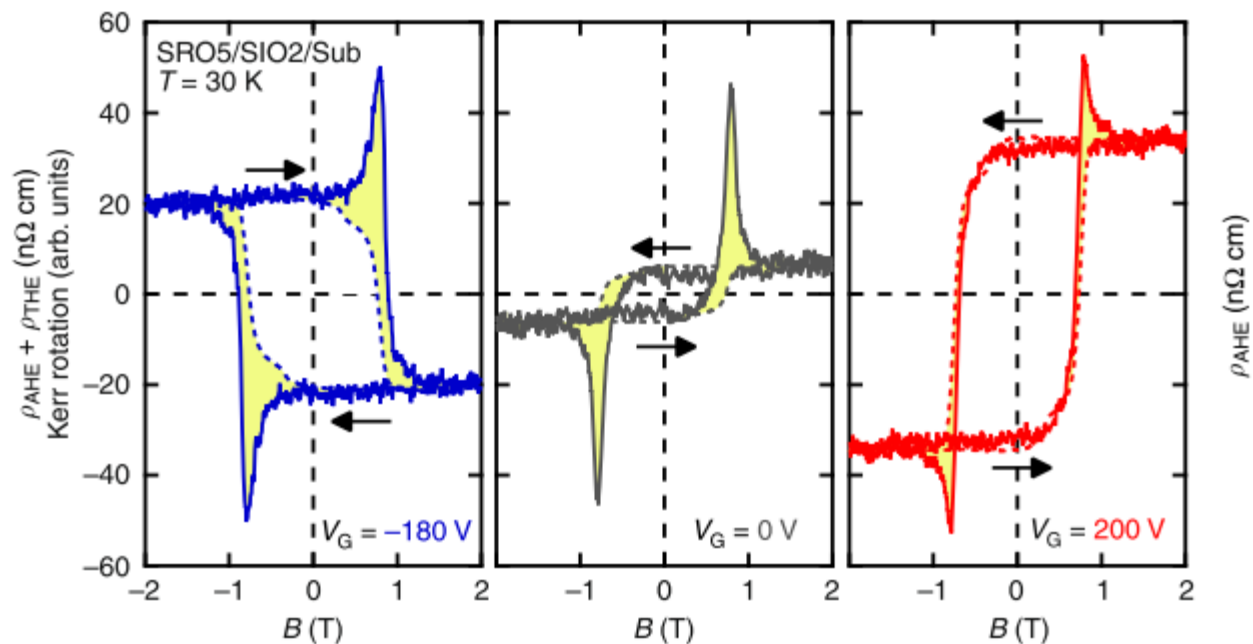
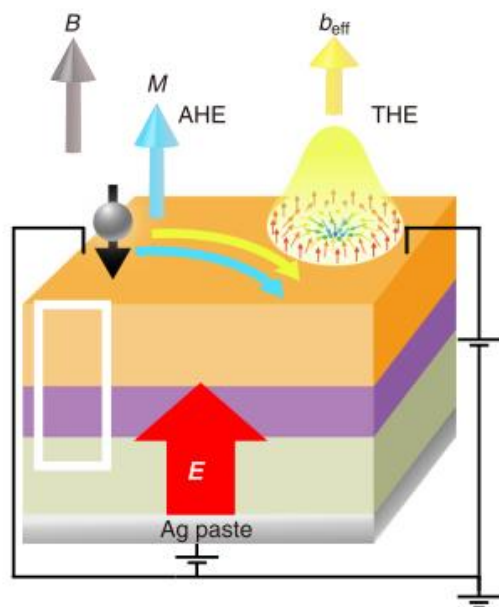
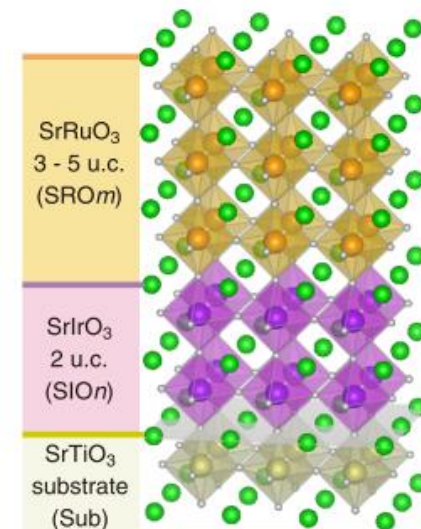
ARTICLE

DOI: 10.1038/s41467-017-02629-3

OPEN

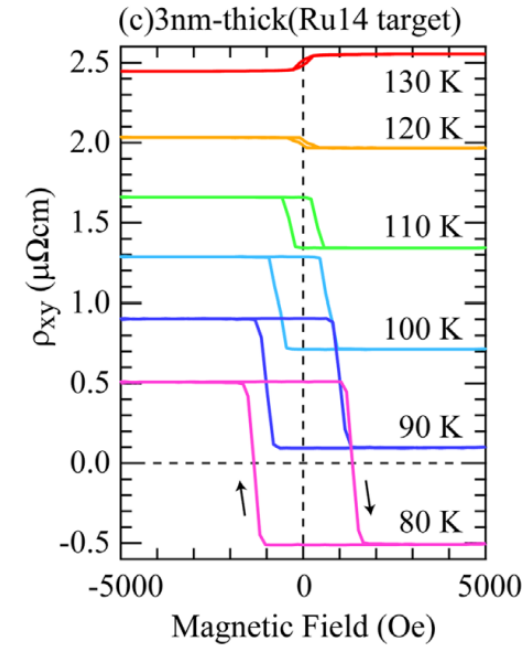
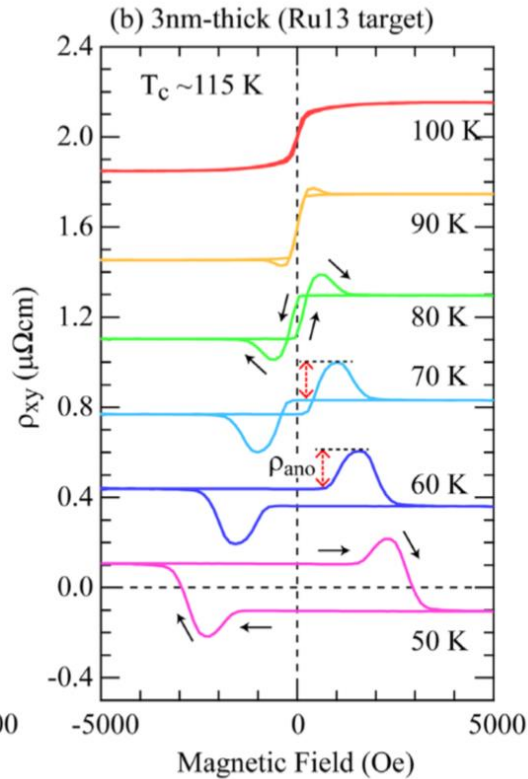
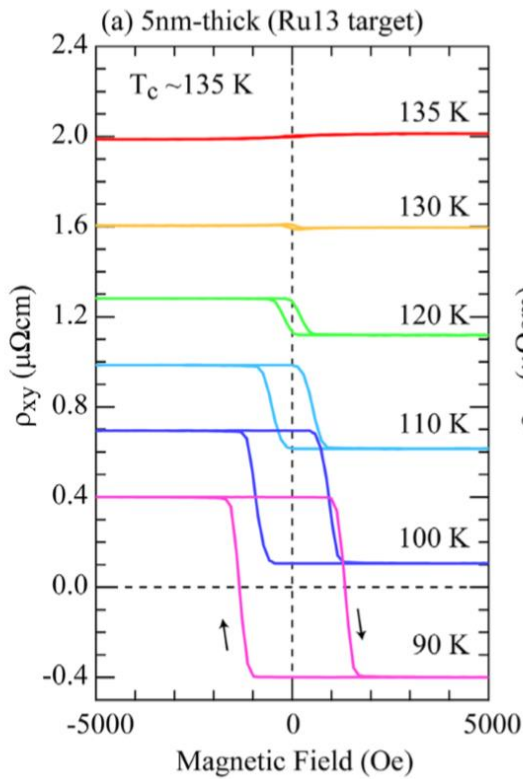
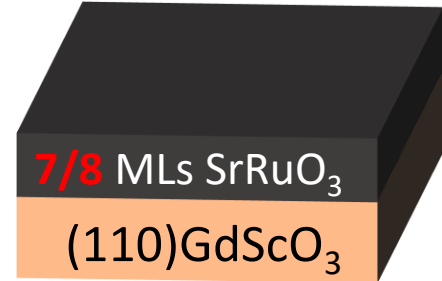
Electric-field control of anomalous and topological Hall effects in oxide bilayer thin films

Yuki Ohuchi¹, Jobu Matsuno², Naoki Ogawa², Yusuke Kozuka¹, Masaki Uchida¹,
Yoshinori Tokura^{1,2} & Masashi Kawasaki^{1,2}



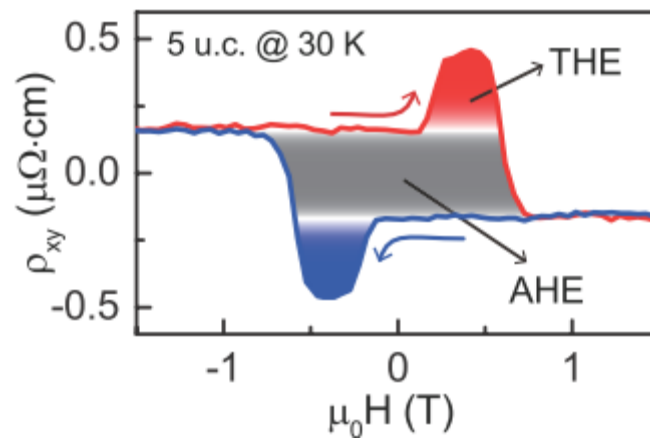
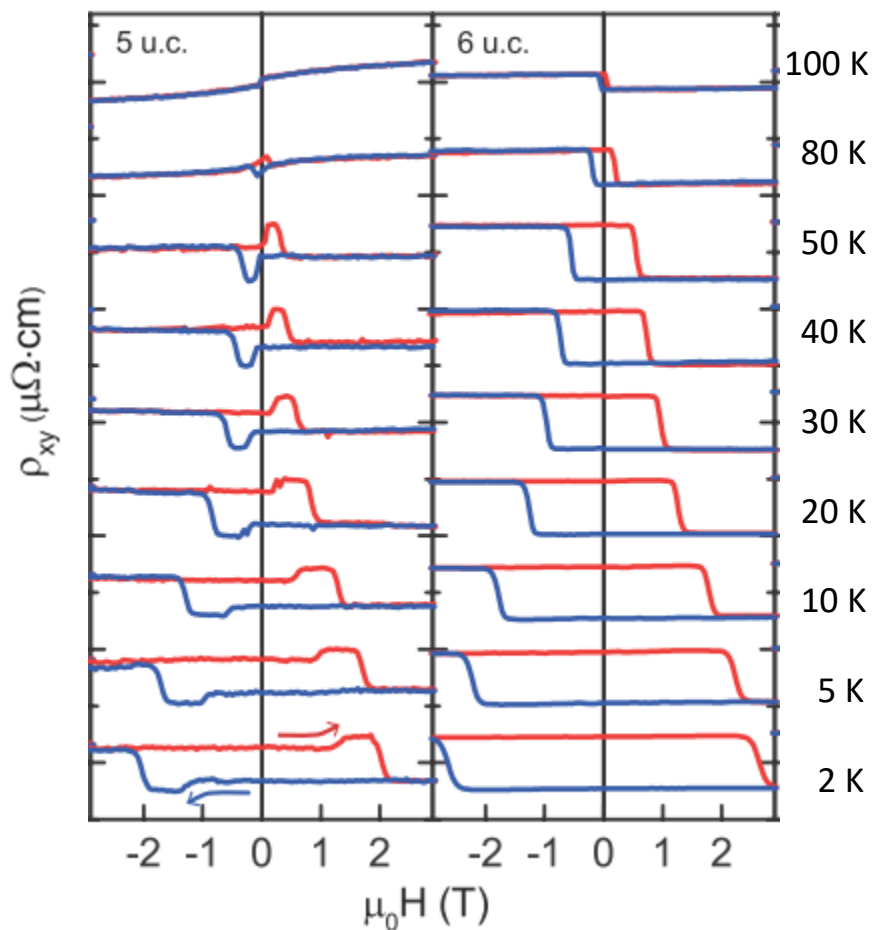
Defect-Induced Anomalous Transverse Resistivity in an Itinerant Ferromagnetic Oxide

Daisuke Kan* and Yuichi Shimakawa



Emergence of robust 2D skyrmions in SrRuO₃ ultrathin film without the capping layer

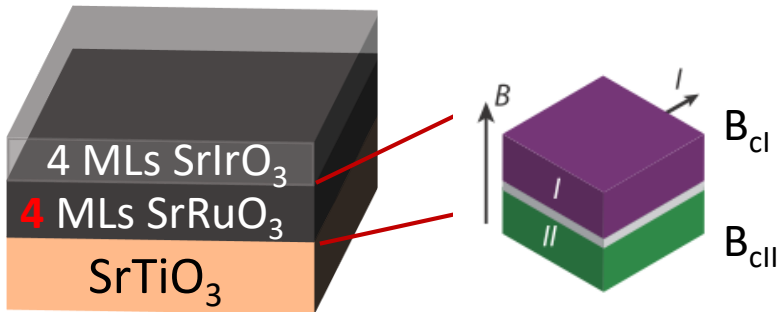
Byungmin Sohn,^{1,2} Bongju Kim,^{1,2,*} Se Young Park,^{1,2} Hwan Young Choi,³ Jae Young Moon,³ Taeyang Choi,⁴ Young Jai Choi,³ Tae Won Noh,^{1,2} Hua Zhou,⁵ Seo Hyoung Chang,^{4,†} Jung Hoon Han,^{6,‡} and Changyoung Kim^{1,2,§}



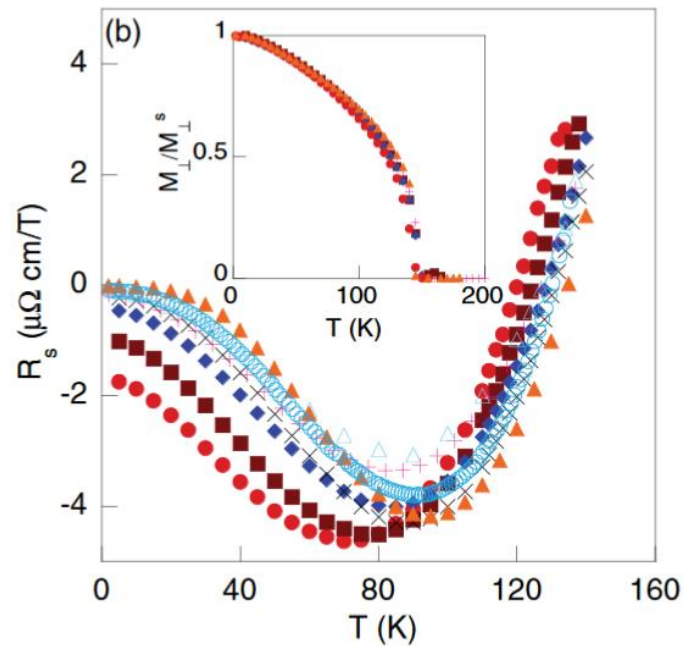
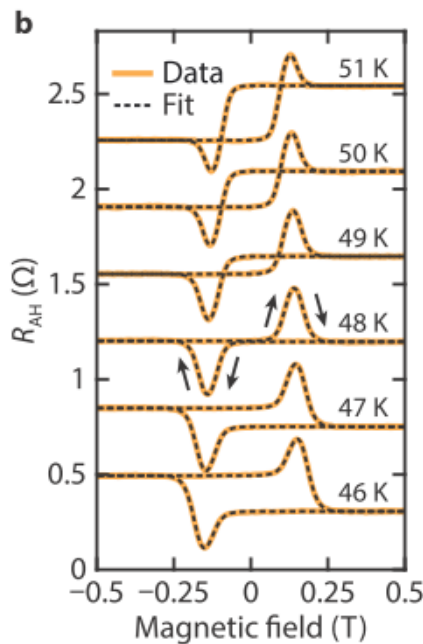
Berry phase engineering at oxide interfaces

12th of October 2018

Dirk J. Groenendijk,^{1,*} Carmine Autieri,^{2,3,†} Thierry C. van Thiel,^{1,†} Wojciech Brzezicki,^{2,3}
 Nicolas Gauquelin,⁴ Paolo Barone,² Karel H. W. van den Bos,⁴ Sandra van Aert,⁴ Johan
 Verbeeck,⁴ Alessio Filippetti,^{5,6} Silvia Picozzi,² Mario Cuoco,^{2,7} and Andrea D. Caviglia^{1,‡}



$$\rho_{\text{anomalous Hall}} = R_A M_z$$

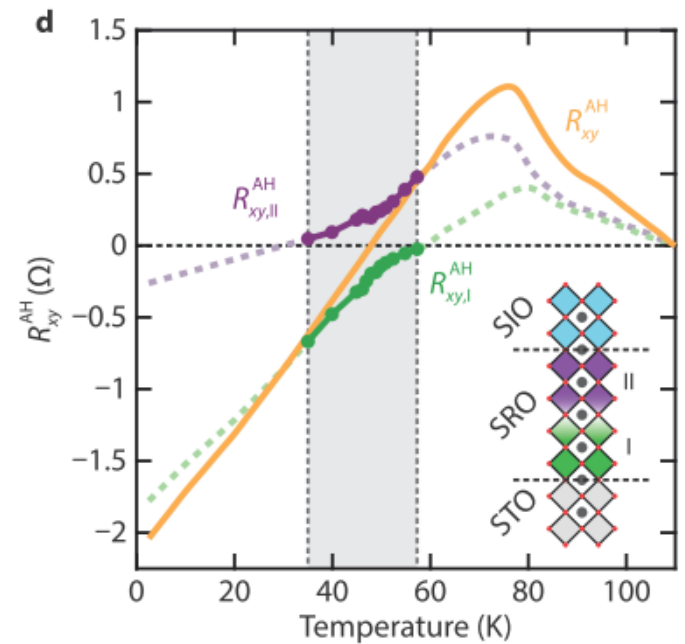
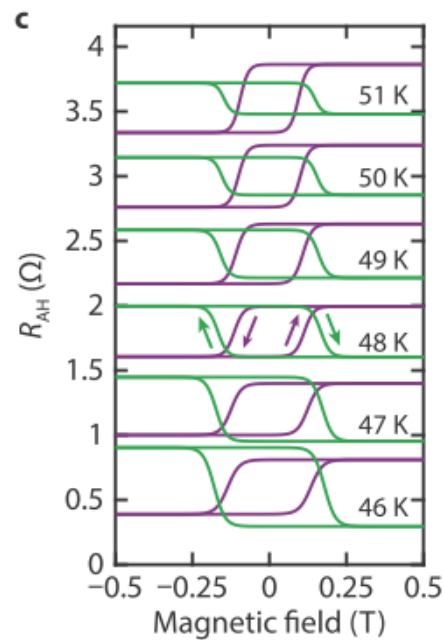
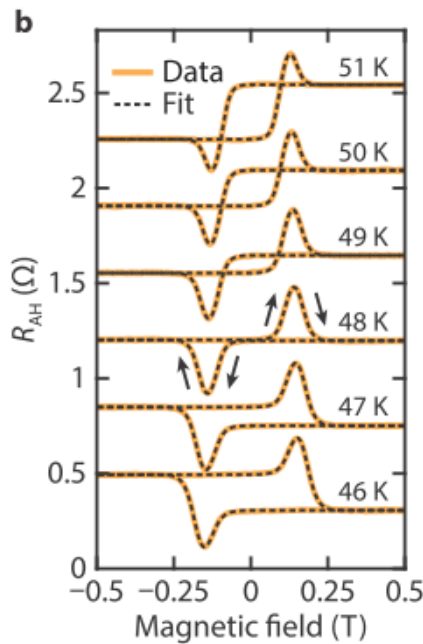
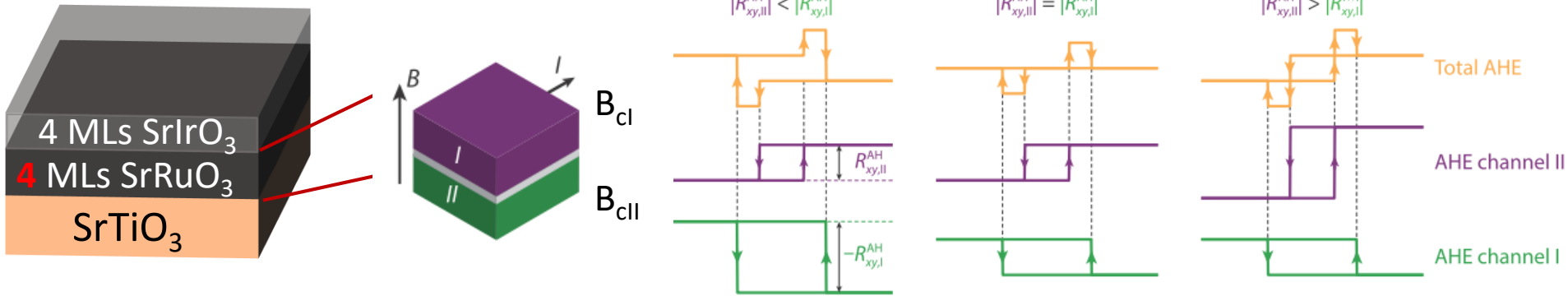


Haham et al.,
 Physical Review B
 84, 174439 (2011)

Berry phase engineering at oxide interfaces

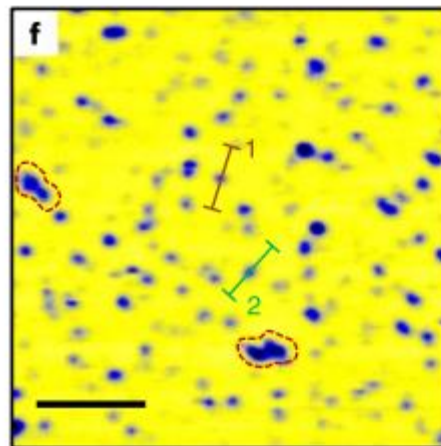
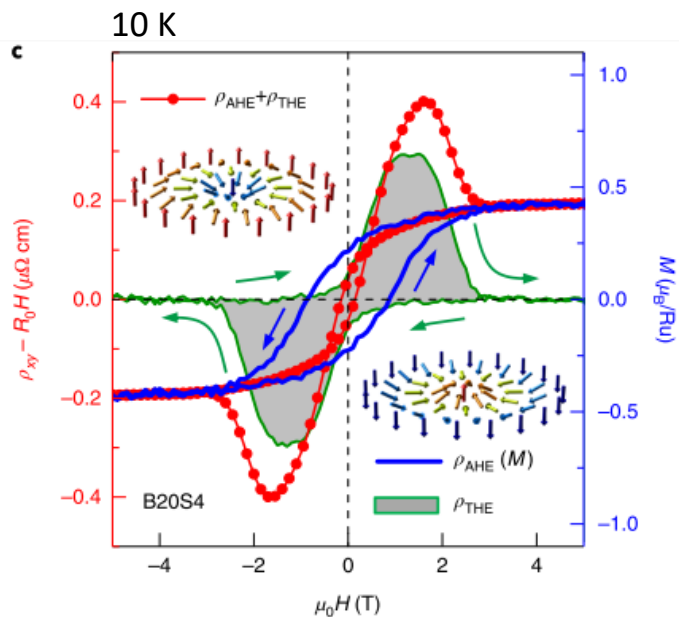
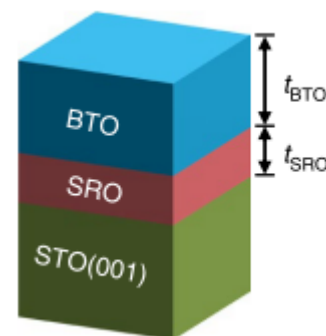
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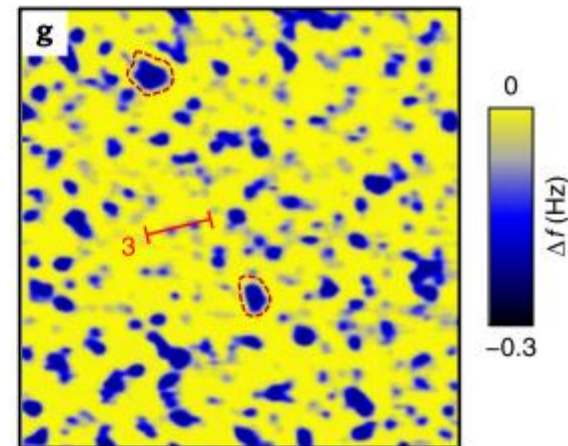


Ferroelectrically tunable magnetic skyrmions in ultrathin oxide heterostructures

Lingfei Wang^{1,2*}, Qiyuan Feng^{3,4,8}, Yoonkoo Kim^{5,8}, Rokyeon Kim^{1,2,8}, Ki Hoon Lee^{1,2,8}, Shawn D. Pollard⁶, Yeong Jae Shin^{1,2}, Haibiao Zhou^{1,2,3}, Wei Peng^{1,2}, Daesu Lee^{1,2}, Wenjie Meng³, Hyunsoo Yang⁶, Jung Hoon Han⁷, Miyoung Kim⁵, Qingyou Lu^{3,4*} and Tae Won Noh^{1,2*}



c – b: $\Delta H = -0.02 \text{ T}$, $\Delta n = 127 \pm 19$



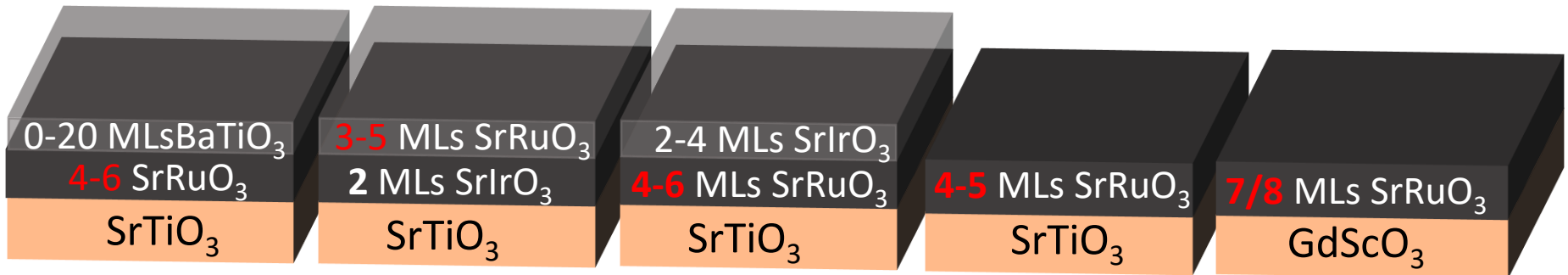
d – c: $\Delta H = -0.08 \text{ T}$, $\Delta n = 376 \pm 121$

skyrmions

Noh group

Kawasaki group

Kim group



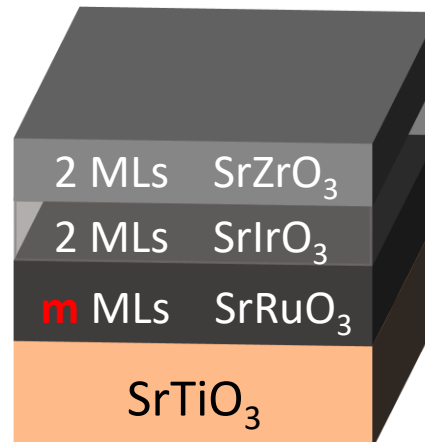
Caviglia group

Kan and Shimakawa

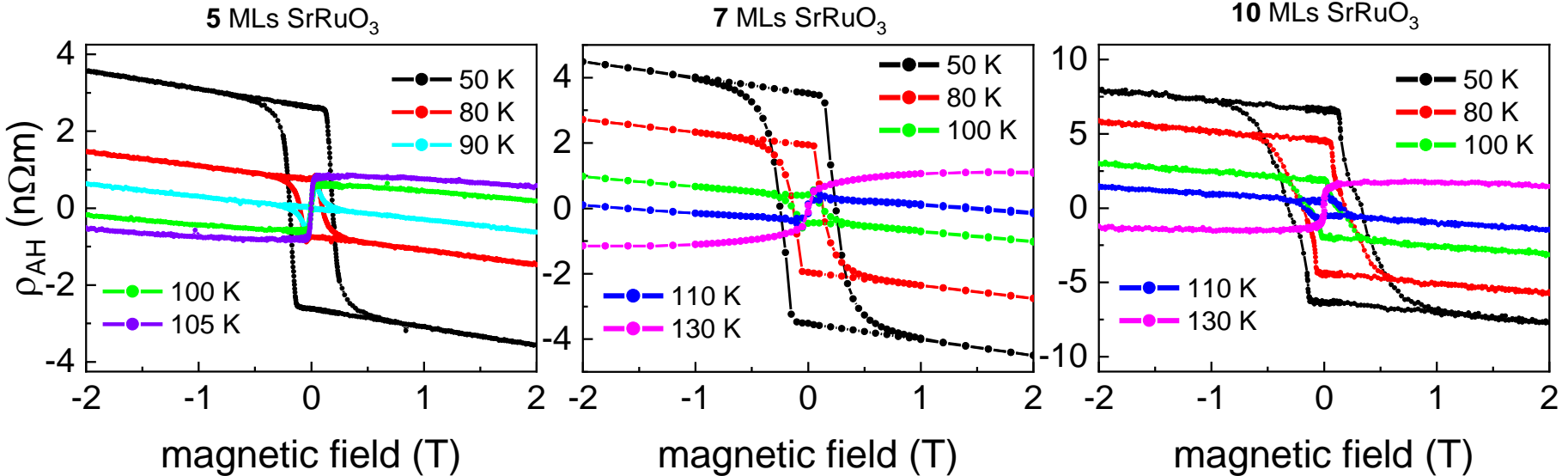
bandstructure modifications -> influence on AHE

Asymmetric multilayers with varying SrRuO_3 layer thickness:

$6 \cdot [m \text{ MLs } \text{SrRuO}_3 / 2 \text{ MLs } \text{SrIrO}_3 / 2 \text{ MLs } \text{SrZrO}_3]$



Multilayers: Hall resistivity



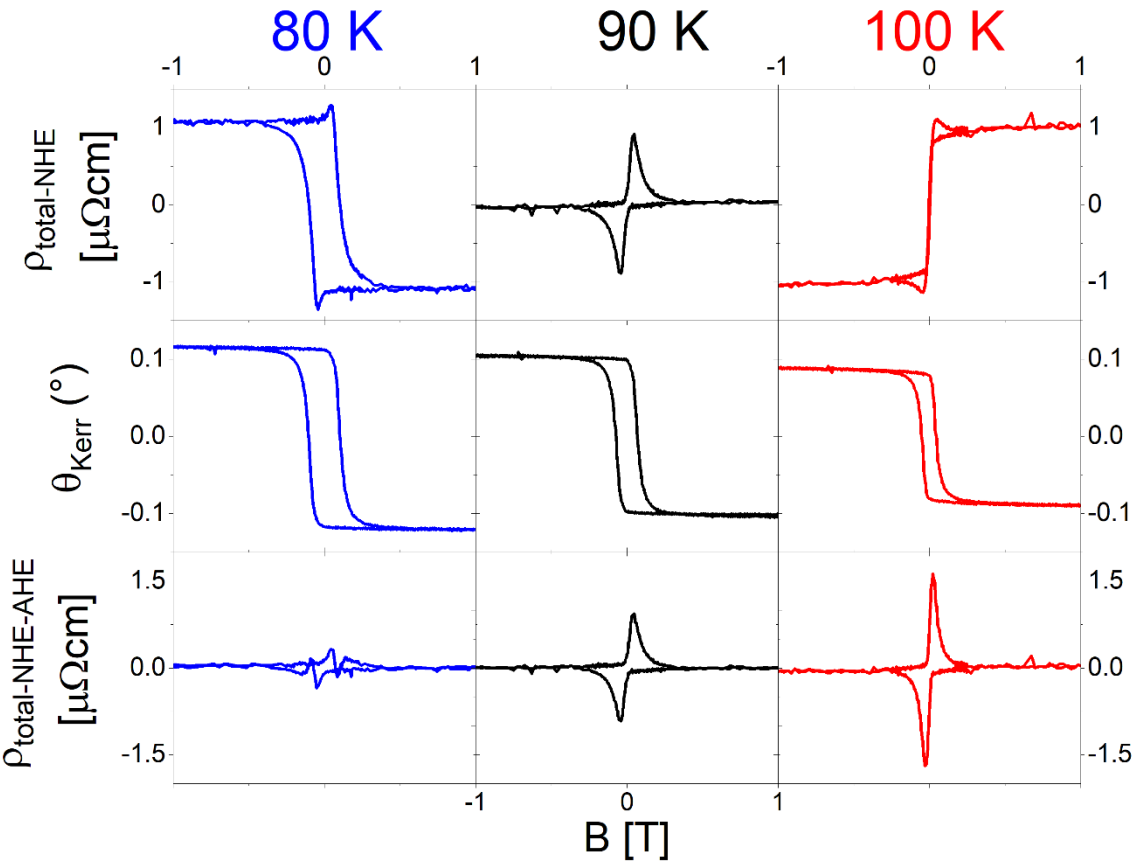
linear contribution:
ordinary Hall effect

hysteresis shape:
anomalous Hall effect

Our multilayers vs bilayers

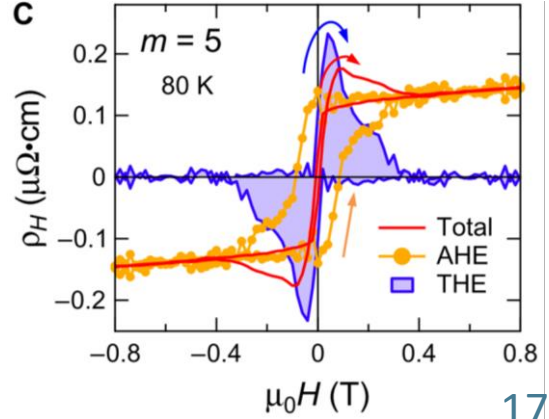
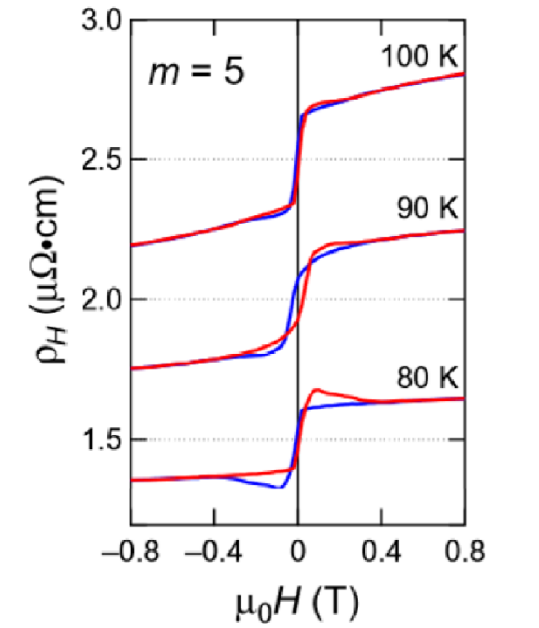


6*(5 MLs SrRuO₃/2 MLs SrIrO₃/2 MLs SrZrO₃)



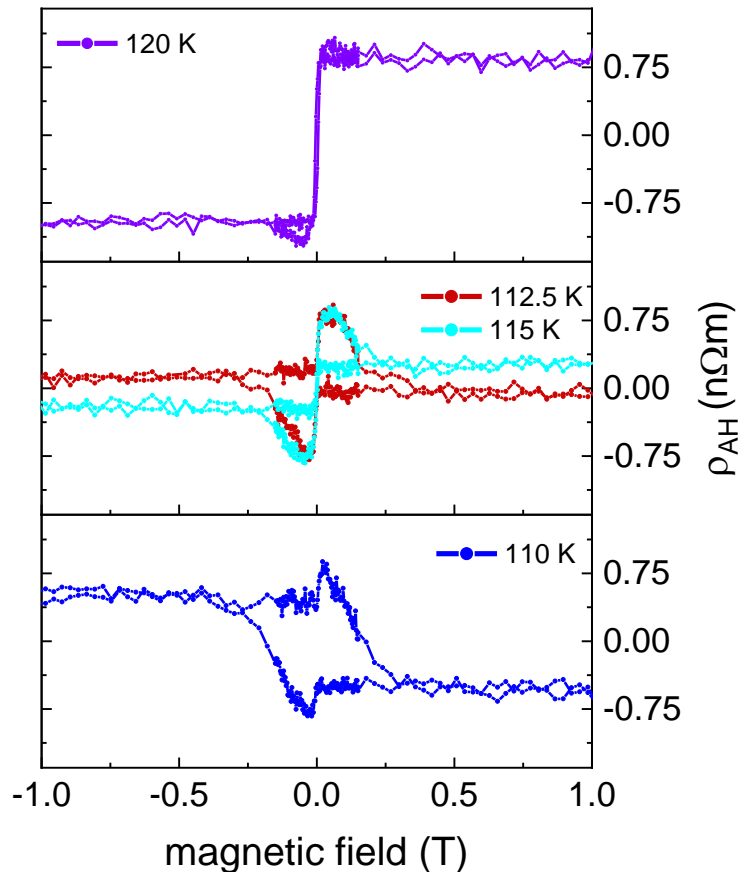
Measurements performed by Jörg and Ramil

5 MLs SrRuO₃/2 MLs SrIrO₃

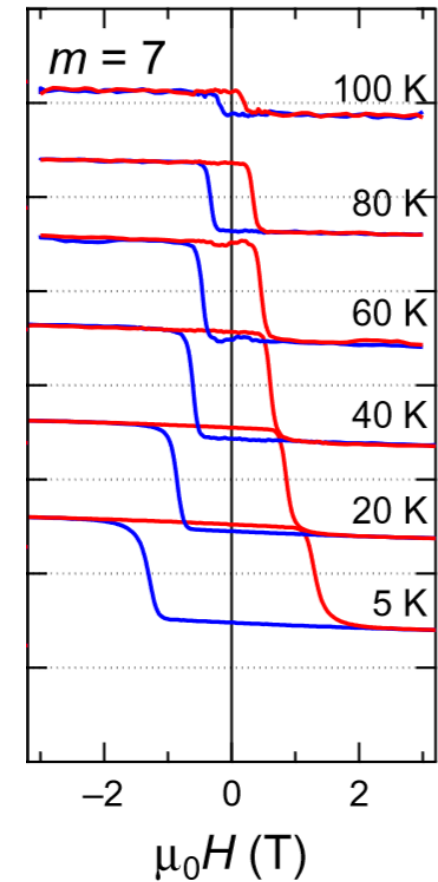


Our multilayers vs bilayers

6* (**10** MLs SrRuO₃/2 MLs SrIrO₃/2 MLs SrZrO₃)



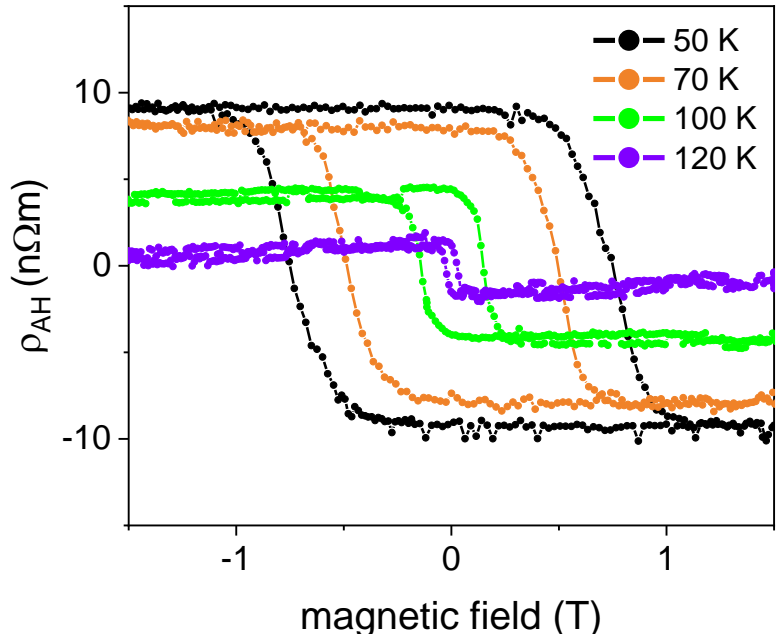
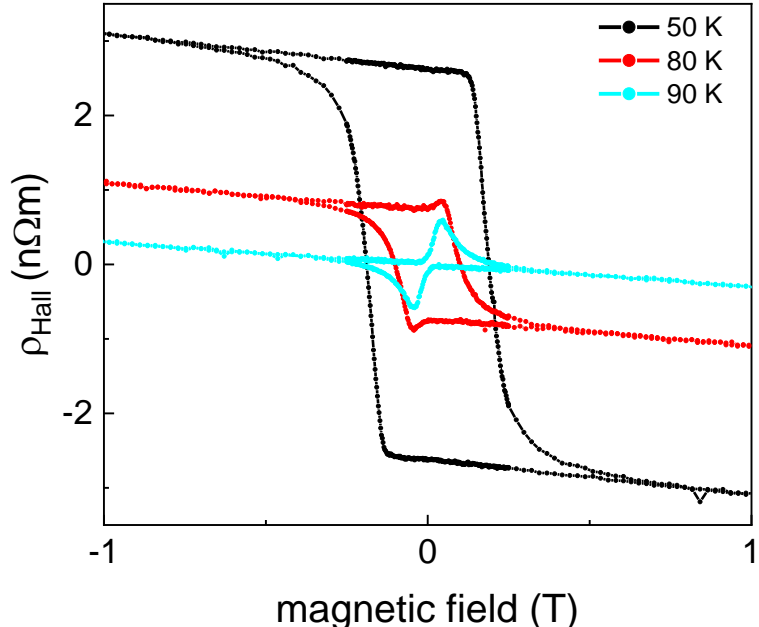
7 MLs SrRuO₃/2 MLs SrIrO₃



Influence of the interface



Measurements performed by Jörg



Thank you for your attention 😊